



IFW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Tomoe MIYAZAWA et al.

Group Art Unit: 2826

Application No.: 10/695,773

Examiner: E. Pert

Filed: October 30, 2003

Docket No.: 117641

For: MALEIC ACID AND ETHYLENE UREA CONTAINING FORMULATION FOR
REMOVING RESIDUE FROM SEMICONDUCTOR SUBSTRATE AND METHOD
FOR CLEANING WAFER

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the March 11, 2005, *Ex parte Quayle* Action, please consider the
following:

Amendments to the Specification;

Amendments to the Claims as reflected in the listing of claims;

Remarks.